IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of: Date: July 29, 2003

  Chun Ying et al.   Docket No.: CN920020005US1

Serial No. To be assigned

Filed: Herewith

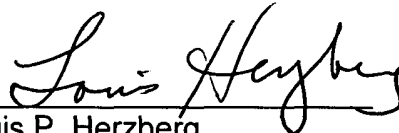For: ENVIRONMENT AWARE MESSAGE DELIVERY SYSTEM

Commissioner for Patents
Mail Stop PATENT APPLICATION
P.O. BOX 1450
ALEXANDRIA, VA 22313-1450

INFORMATION DISCLOSURE STATEMENT

Sir:

In order to assist in the examination of this application, and in accordance with 37 CFR 1.56, 1.97 and 1.98, copies of the documents listed on the attached form PTO-1449 are forwarded herewith.

The Director is hereby authorized to charge payment of any fee necessary to enter this paper to Deposit Account No. 09-0468.

By: _____
    Louis P. Herzberg
    Reg. No. 41,500
    (914) 945-2885

IBM Corporation
Intellectual Property Law Dept.
P. O. Box 218
Yorktown Heights, New York 10598

ATTY. DOCKET NO.	SERIAL NO. To be assigned
CN920020005US1	Express Mail : EV309868573US
	Date of Deposit: August 1, 2003
APPLICANT: **Chun Ying et al.**	
FILING DATE: Herewith	GROUP:

REFERENCE DESIGNATION · · · · · · · **U.S. PATENT DOCUMENTS**

EXAMINER INITIALS		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE (IF APPRO.)
	AA	6,009,333	12/28/1999	Chaco			
	AB	6,266,513 B1	07/24/2001	Briancon			
	AC	6,356,192 B1	03/12/2002	Menard et al.			
	AD	2002/0006787	01/17/2002	Darby			
	AE	2002/0004387 A1	01/10/2002	Newville			
	AF	2002/0013144 A1	01/31/2002	Waters et al.			
	AG	2002/0005834 A1	01/17/2002	Oh			
	AH	2002/0029258 A1	03/07/2002	Mousseau et al			
	AI						
	AJ						
	AK						

FOREIGN PATENT DOCUMENTS

		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
							YES	NO
	AL							
	AM							
	AN							
	AO							
	AP							

OTHER ART (Including Author, Title, Date, Pertinent Pages, etc.)

	AQ	
	AR	
	AS	
	AT	
	AU	

EXAMINER	DATE CONSIDERED

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance <u>and</u> not considered. Include copy of this form with next communication to applicant.